第 97 回ナノ・スピン工学研究会 第 21 回 CSIS セミナー スピントロニクス研究室講演会の開催について

日 時: 平成29年12月11日(月)10:00-11:30

場 所: 電気通信研究所 ナノ・スピン総合研究棟4階 401 号室

講 師: Professor Thibaut Devolder

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講演題目: Nanosecond-scale STT switching in perpendicularly magnetized STT-MRAM cells

概要 We studied experimentally the nanosecond-scale spin-torque-induced switching in perpendicularly magnetized tunnel junctions. The samples are improved CoFeB/MgO based systems with sizes varied between 40 and 500 nm, coming from collaborations with either IMEC Belgium or SAMSUNG E. C.. The electrical signatures of the STT-induced sub-threshold switching indicate non-uniform magnetization reversal with the presence of a domain wall in junctions of various sizes. A nucleation phase is followed by an irreversible and regular flow of a wall through the sample at an average velocity of 10-40 m/s (depending on the material parameters) with features indicating a turbulent Walker propagation regime in the largest samples. Once initiated, the duration of the switching correlates with the free layer diameter: smaller is faster. The resulting electrical signature of the reversal can be reproduced with a simple model in which the parameters ó in particular the exchange stiffness ó are extracted from device-level spin-wave spectroscopy.